

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	3547	(359/566,576,900).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:38
S2	1097	(359/566,576).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:38
S3	2510	(359/900).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:38
S4	98961	(grating or diffract\$3 near1 element)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:45
S5	18397	(calcium or barium) adj fluoride or (CaF2 or BaF2)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:47
S6	835696	(silicon adj dioxide or silicon adj oxide or silica or quartz)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:47
S7	399	S4 and S5 and S6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:47
S8	818	((calcium or barium) adj fluoride or (CaF2 or BaF2)) with substrate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:42
S9	55	S4 and S8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:48
S10	43	S6 and S9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 13:49

S11	98961	(grating or diffract\$3 near1 element)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:27
S12	818	((calcium or barium) adj fluoride or (CaF2 or BaF2)) with substrate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:22
S13	55	S11 and S12	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:34
S14	18397	(calcium or barium) adj fluoride or (CaF2 or BaF2)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:36
S15	835696	(silicon adj dioxide or silicon adj oxide or silica or quartz)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:35
S16	399	S11 and S14 and S15	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:34
S17	158	S16 and etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:36
S18	100	S17 and (resist or photoresist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:37
S19	166597	((silicon adj dioxide or silicon adj oxide or silica or quartz) with layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:21
S20	86	S11 and S14 and S19	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 16:09

S21	47	S20 and etch\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:36
S22	33	S21 and (resist or photoresist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 14:37
S23	1097	(359/566,576).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:21
S24	67	S23 and ((silicon adj dioxide or silicon adj oxide or silica or quartz) with layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:35
S25	1	S24 and (((calcium or barium) adj fluoride or (CaF2 or BaF2)) with substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:22
S26	860	(216/24,26).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:35
S27	261	S19 and S26	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:35
S28	3	S14 and S27	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:41
S29	7303	(430/5).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:41
S30	1211	S19 and S29	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:42

S31	88	S14 and S30	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:42
S32	6	S13 and S30	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:52
S33	2510	(359/900).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:52
S34	375	S33 and S11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 15:53
S35	5	S14 and S15 and S34	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2004/12/28 16:08
S36	1	("6268952").PN.	USPAT	OR	OFF	2004/12/28 17:19